

Hui Yang

List of Publications by Year in descending order

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5
papers

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1937685

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2053705

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times ranked

36
citing authors

#	ARTICLE	IF	CITATIONS
1	Enhancement-mode thin film transistor using amorphous phosphorus-doped Indium-Zinc-Tin-Oxide channel layer. <i>Materials Science in Semiconductor Processing</i> , 2022, 137, 106228.	4.0	7
2	Influence of oxygen flow during sputtering process on the electrical properties of Ga-doped InZnSnO thin film transistor. <i>Semiconductor Science and Technology</i> , 2021, 36, 045006.	2.0	5
3	Annealing atmosphere-dependent electrical characteristics and bias stability of N-doped InZnSnO thin film transistors. <i>Materials Science in Semiconductor Processing</i> , 2020, 113, 105040.	4.0	12
4	Annealing temperature effects on the structural and electrical properties of N-doped In-Zn-Sn-O thin film transistors. <i>Journal of Alloys and Compounds</i> , 2019, 801, 33-39.	5.5	13
5	Preparation and electrical characteristics of N-doped In-Zn-Sn-O thin film transistors by radio frequency magnetron sputtering. <i>Journal of Alloys and Compounds</i> , 2018, 750, 1003-1006.	5.5	11